Workshops and Events



Professional Workshops

Technical sessions that cater to the interests and needs of the professional community. Experts present topics related to various research thrusts and associated process technologies currently available within the LNF. Lectures are accompanied by hands-on laboratory activities that benefit professionals from diverse backgrounds.



Seminars and community events for academic and professional networking, outreach to the general public, and many more events including our annual LNF Users Symposium.







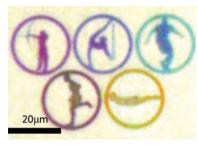
Prof. Euisik Yoon, Faculty Director **Dr. Sandrine Martin**, Managing Director



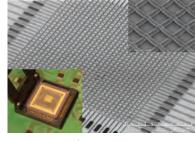
Transparent, superomniphobic microfabricated surface to repel all liquids.



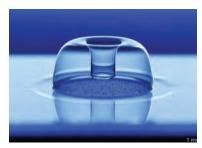
High-efficiency stackable AlGaAs photovoltaics for indoor energy harvesting in mm-scale wireless sensor systems.



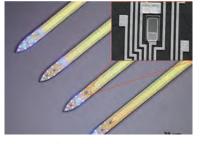
Structural colors and ultra-condensed images based on metallic nanocavities with 40 to 90nm-wide nanogrooves.



Crossbar array of metal oxide memristive devices (memristors) for neuromorphic applications.



Fused silica-based atomically smooth shell resonator for high-performance gyroscopes.



Monolithically integrated µLEDs on silicon neural probes for high-resolution optogenetics.

University of Michigan

Lurie Nanofabrication Facility (LNF)







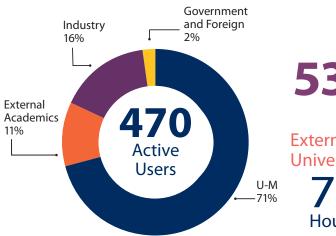








LNF Community



Hours of Lab Usage

Benefits

Access to a world-class facility providing a broad set of technologies and processes, with technical support from process engineers and domain experts.

FREE project consultation for prospective users

FREE initial assistance from experienced process engineers and scientists

FREE safety and equipment training

FREE access to a web-based equipment reservation system

SHARED office space with internet access and CAD software

REDUCED capital investment necessary to initiate a research project

OWNERSHIP of intellectual property by users

Regents of the University of Michigan: Michael J. Behm, Grand Blanc; Mark J. Bernstein, Ann Arbor: Laurence B. Deitch, Bloomfield Hills: Shauna Ryder Diggs, Grosse Pointe; Denise Ilitch, Bingham Farms; Andrea Fischer Newman, Ann Arbor; Andrew C. Richner, Grosse Pointe Park; Katherine E. White, Ann Arbor; Mark S. Schlissel, ex officio

A Non-discriminatory, Affirmative Action Employer

The mission of the LNF is to provide effective, efficient, safe, and socially responsible access to advanced nanofabrication equipment and expertise thereby promoting, enabling, and *encouraging cutting-edge* education, research and business development from materials and individual process steps to entire systems.

Lurie Nanofabrication Facility:



Complete Fabrication Capabilities:

- More than 13,500 square feet (area under filter) of state-of-the-art class 10/100/1000 and 10,000 with up to 6" (150mm) processing capability and BioSafety Level II facility
- Comprehensive suite of tools that support:
- General processing, Silicon, compound semiconductors, polymers, and other materials
- MEMS, BioMEMS
- Optoelectronics
- CMOS, MEMS-CMOS integration
- Microfluidics

Domain Experts for:

- General micro/nanofabrication
- MEMS, BioMEMS, integrated microsystems
- Nanophotonics, nanolithography
- Surface science, electrochemistry, material science

LNF Process Capabilities

Deposition and Growth

CVD, ALD, LPCVD, PECVD, PVD, Parylene Deposition

Lithography, Direct Writing and Mask Making

Your Resource to Enable Innovation

Optical Lithography, E-beam Lithography, Soft Lithography, Mask Making, InkJet Printing, Dip-Pen Nanolithography



Etching

RIE, DRIE, XeF2

Thermal Processing

Annealing, Oxidation, Doping and Diffusion

Chemical Processing

Wet Etching, Lift-Off, Electroplating

Metrology and Characterization

SEM, AFM, Profilometry, Microscopy (IR, Fluorescent), Ellipsometry, Reflectometry, EDS, μFTIR, 4-pointProbe, Film Stress, Contact Angle



Wafer Bonding, Dicing, Wire Bonding, Flip-Chip Bonding, Polishing, Lapping, CMP











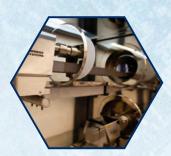
Lurie Nanofabrication Facility

As a new faculty member at the University of Michigan, are you aware of the ways that the Lurie Nanofabrication Facility (LNF) can benefit your research program?

The LNF includes 11,000 sq.ft. of class 10/100/1000 space, plus 2,500 sq.ft. of quasi class 10,000 with a BioSafety Level 2 space, and provides not only outstanding process capabilities, but also highly experienced staff for training and technical support.

We offer flexibility in usage modalities from extensive lab usage, to users who may only need to perform a few key processes throughout the year, to process services performed by our staff engineers and scientists.

Email us to discuss your specific needs and how we can help. We look forward to working with you on high impact research and hope to hear from you soon!













734-277-2365 www.LNF.umich.edu





Lurie Nanofabrication Facility



For more information:

www.LNF.umich.edu info@LNF.umich.edu
LNF-wiki.eecs.umich.edu



Lurie Nanofabrication Facility

Process Services



OVERVIEW

The University of Michigan Lurie Nanofabrication Facility (LNF) includes 11,000 sq. ft. of class 10/100/1000 cleanroom and 2,500 sq. ft. of quasi class 10,000 space with a BiosSafety Level 2 space. The LNF provides a wide range of fabrication and characterization capabilities and our highly experienced scientists and engineers are here to help you with your process needs. The LNF offers processing services to researchers unable to come to work onsite themselves.



- E-beam lithography
- DRIE
- Wafer Bonding
- Thermal Processes

- Soft Lithography
- Analytical Services
- Thin Films and many more!

See complete list of capabilities.

Lnf-wiki.eecs.umich.edu/
LNF.umich.edu info@LNF.umich.edu









